

Amendments to the Specification

Please amend the text at page 10, lines 5 to 7, as shown below:

a The use of external heating ~~yields the allowance of~~
b enables the independent control of the temperature of
glass substrate 320 ~~temperature~~ and magnetic flux
density on silicon film ~~films~~ 220, which is not the
case in the embodiments of FIGS 1 and 2.
